



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

July 23, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

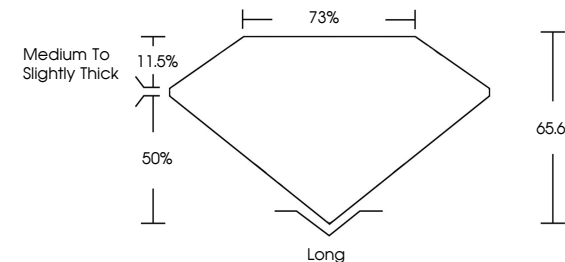
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

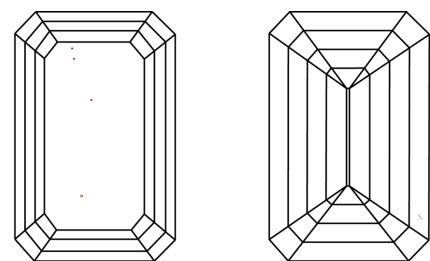
LG818689107

Report verification at igi.org

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

CLARITY

Sample Image Used



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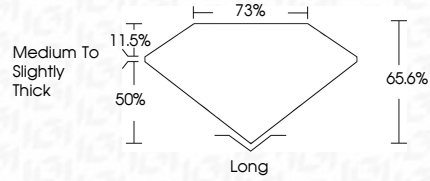
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PROPORTIONS



COLOR

CLARITY

Sample Image Used



LABORATORY GROWN DIAMOND REPORT

July 23, 2026

IGI Report No LG818689107

EMERALD CUT

8.56 X 6.54 X 4.29 MM

2.40 CARATS

G

VS 1

EXCELLENT

EXCELLENT

NONE

IGI LG818689107

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IGI



July 23, 2026

IGI Report No LG818689107

EMERALD CUT

8.56 X 6.54 X 4.29 MM

2.40 CARATS

G

VS 1

73%

65.6%

Medium to Slightly Thick

Long

EXCELLENT

EXCELLENT

NONE

IGI LG818689107

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